

PVD Sputtered Films Available

Al ₂ O ₃ (Reactive & Non-Reactive)	Ge	Ti ₂ Ce ₂ O ₃
AlCu (.5)	GeSbTe	TiN (Reactive)
AlCu (1)	ITO	TiNi
AlCu (4)	Mo	Ti ₅ Si ₃
AlMg	MoSi (2)	TiSi ₂
AlSi (1)	Nb	TiO ₂ (Reactive & Non-Reactive)
AlSi (.1)	Ni	W
AlSi (2)	NiCr (80/20)	WSi (2.7)
AlSi (40ppm)	NiCr (60/40)	WTi (90/10)
AlSiCu (1/.5)	NiFe (19)	WTi (80/20)
AlSiCu (1/1)	NiP	Zr
AlCuSi (2/1)	NiV (7)	ZrO ₂ (Reactive & Non-Reactive)
Ag	Pd	
Al	Pt	
Au	Si	
C	Si (Undoped)	
CeO ₂ Se ₂ O ₃	SiC	
Co	SiCr (60/40)	
Cr	Si ₃ N ₄ (reactive)	
Cr ₂ O ₃ (Non-Reactive)	SiO ₂ (Reactive & Non-Reactive)	
CrSi	Sn	
Cr ₂ O ₃ TiO ₂ (Non-Reactive)	Ta	
Cr ₂ O ₃ Al ₂ O ₃ (Non-Reactive)	Ta ₂ O ₅ (Non-Reactive)	
Cu	TaAl	
CuNi (60/40)	TaN (Reactive)	
CrMo (90/10)	Ti	
Fe		
FeCo (60/40)		
FeCo (75/25)		

